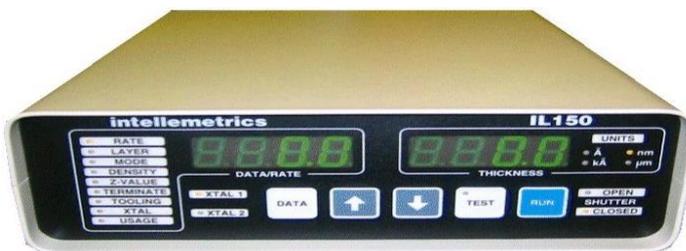


Thin Film Deposition



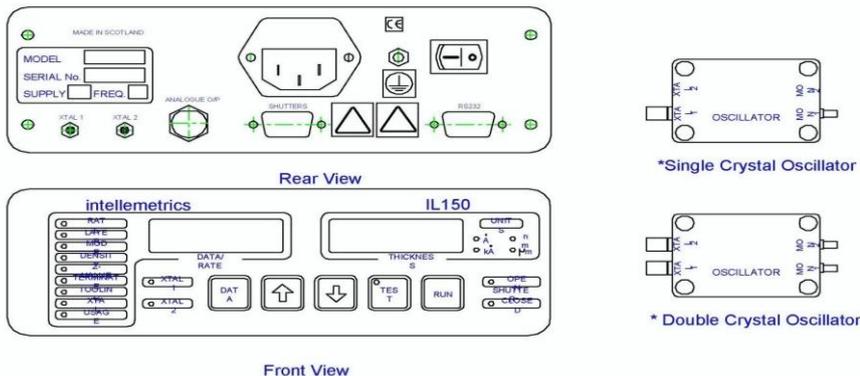
IL150 Quartz Crystal Film Growth Rate Monitor



The IL150 thin film deposition monitor measures film thickness and deposition rate by the well-established crystal microbalance technique. Thickness and deposition rate are calculated from user-supplied data on density and acoustic impedance of the film material. Data for up to eight films can be stored in non-volatile memory. Up to two sensor heads may be connected to the instrument at any one time: two alternative modes allow the second crystal to be used either as a backup in the event of failure of the first sensor, or as an alternative primary sensor selectable according to the film being deposited. User specified 'Tooling Factors' compensate for different detector/substrate geometries so that the monitor may be used on a number of different deposition systems.

FEATURES

- Thickness, Rate of deposition, parameter and system information displayed on 4digit, 7segment, 0.7" LED's
- Thickness Range : 0.0nm to 999.9 microns
- Thickness Resolution : 0.1nm(1Å)
- Shutter Closure : Predictive termination using current rate and last thickness measured
- Film parameters recordable in memory
- Density : 0.1 to 99.9 gm/cm³
- Acoustic Impedance : 1.0 to 99.9*10⁵ gm/cm²/sec
- Terminal Thickness : 0.1 nm to 99.9 microns, autoranging
- Size : 260mm X 88mm X 205mm



* The Oscillator is shipped with the Sensor Head-NOT with the IL150

Fig.2

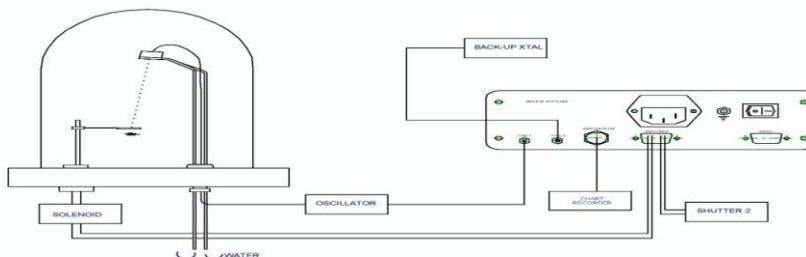


Fig 5 System Layout

Deposition Monitor / Controller

Accessory

Electron 12 Crystal Sensor Head

- 12 Point Sensing Head
- By utilizing an in-vacuum stepper motor system for crystal indexing



Electron 24 Crystal Sensor Head

- 24 Point Sensing Head
- By utilizing an in-vacuum stepper motor system for crystal indexing



Sensor Head with Thermocouple and Feedthrough

- CF 2.75"/ 1" Bolt/ KF40



Micro Coaxial Crystal Head Cable

- Each cable is 30" long
- Maximum of 250°C



RC Quartz Monitor Crystals

- Gold, Aluminium



RC Liquid Monitor Crystals

- 1 inch diameter



Deposition Monitor / Controller

PC-based Film-Thickness Monitor

Device Parameter

Density	0,10 to 99,99 [g/cm ³]
Z-Factor	0,00 to 15,00
Rate Setpoint	0,00 to 9999,99 [Å/s]
Thickness Set Point	0,00 to 9999,99 [KÅ]

Measurement

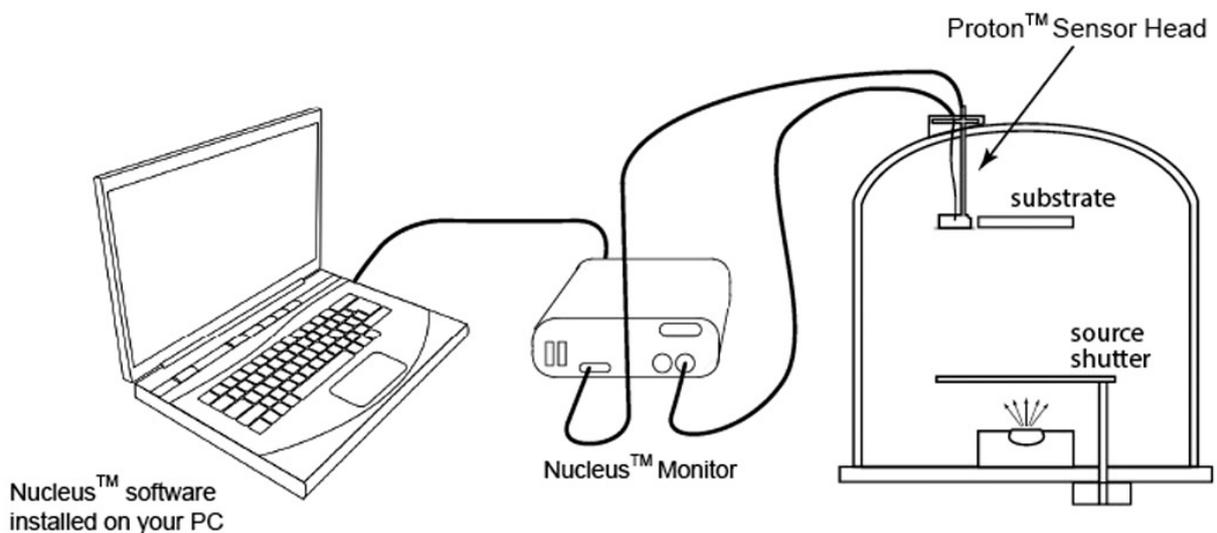
Frequency Resolution	+/-0,002 [Hz]
Display Rate	10X to 1X per second
Crystal Frequency Range	5 or 6 [MHz]

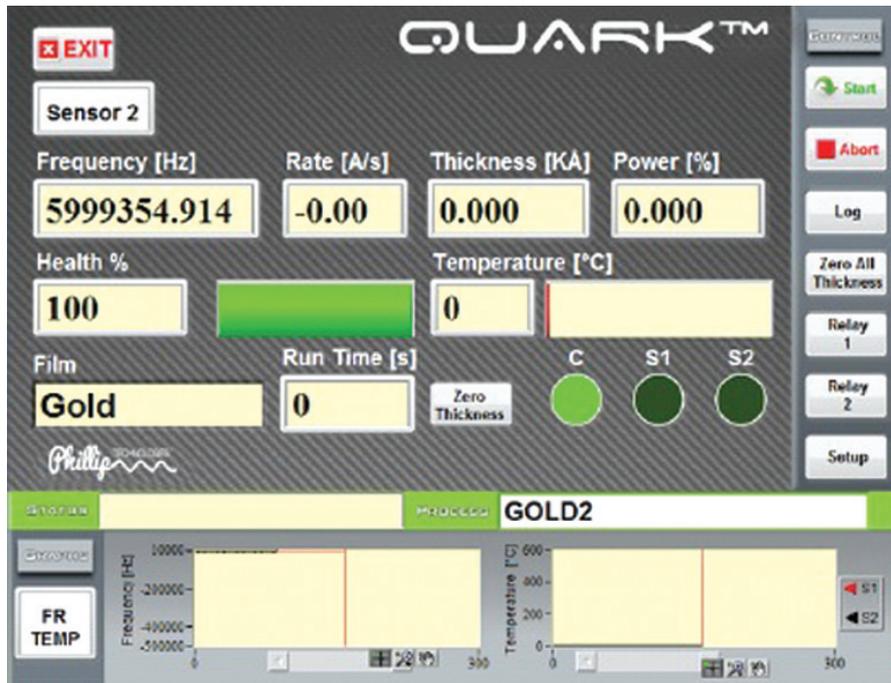
Process Display

Film	Selected Material
Rate	0,00 to 99,9 [Å/s]
Thickness	0,00 to 999,9 [KÅ]
Frequency	-3,00 to 6,500,000 [Hz]
Run Time	Hh/mm/ss
Temperature	0 to 999,9 [°C]
Health	0,00 to 100 [%]

Communications

Factory Set	RS-232 [PC version]
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Display

Thickness	Auto ranging : 999 to 9999.9 kÅ
Rate	Auto ranging : 999 to 9999.9 A
Power	00.00 to 99.99%
Time	0 to 99:59:59 HH:MM:SS
Crystal Health	00 to 99%
Layer Number	0 to 999
Screen	800×480 Full Color Touch Screen

Comm

Standard	RS232
Optional	USB (Process Programming) Ethernet
Creating Programs	All settings can be programmed using the touchscreen and embedded keypad. Keyboard can be connected via the USB port. Cactus Prog™ software can be used on a PC to create layers and can be transferred using a USB flash drive.
Capabilities	Unlimited Layer and Process Programs

Analogue Mass Flow Meter / Controller

MASS FLOW CONTROLLER SPECIFICATIONS

MODEL	FULL SCALE N2(slp _m)	ACCURACY (% FS)	REPEATABILITY (%)	RESPONSE TIME(sec)	IN/OUT SIGNAL (Vdc/mA)	SUPPLY POWER (Vdc)	OPERATING PRESSURE(psia)	OPERATING TEMP(°C)
M3030V	0.010~30	±1.0	±0.25	<2	0~5 or 4~20	+ 15 or 24	5~1300	0~50
M3030A								
M3050V	25~50	±1.0	±0.25	<2	0~5 or 4~20	+ 15 or 24	5~1300	0~50
M3050A								
M3100V	30~100	±1.0	±0.25	<2	0~5 or 4~20	+ 15 or 24	5~1300	0~50
M3100A								
M3300V	100~300	±1.0	±0.25	<2	0~5 or 4~20	+ 15 or 24	5~1300	0~50
M3300A								
M3500V	300~1000	±1.0	±0.25	<2	0~5 or 4~20	+ 15 or 24	5~1300	0~50
M3500A								

MASS FLOW METER SPECIFICATIONS

MODEL	FULL SCALE N2(slp _m)	ACCURACY (% FS)	REPEATABILITY (%)	RESPONSE TIME(sec)	IN/OUT SIGNAL (Vdc/mA)	SUPPLY POWER (Vdc)	OPERATING PRESSURE(psia)	OPERATING TEMP(°C)
M2030V	0.010~30	±1.0	±0.25	<2	0~5 or 4~20	+ 15 or 24	5~1300	0~50
M2030A								
M2050V	25~50	±1.0	±0.25	<2	0~5 or 4~20	+ 15 or 24	5~1300	0~50
M2050A								
M2100V	30~100	±1.0	±0.25	<2	0~5 or 4~20	+ 15 or 24	5~1300	0~50
M2100A								
M2300V	100~300	±1.0	±0.25	<2	0~5 or 4~20	+ 15 or 24	5~1300	0~50
M2300A								
M2500V	300~1000	±1.0	±0.25	<2	0~5 or 4~20	+ 15 or 24	5~1300	0~50
M2500A								

Mass Flow Controllers

Features

- Accuracy at Low Flow
- Fast Response
- No Leakage
- Connection Compactible
- High stable removeable sensor
- Corrosion resistance Value
- Excellent Linerity
- Excellent long term Stability
- Modular design
- Wide pressure Range available
- Compact Flow Control System



Model M3030V
Mass Flow Controller

Specifications

Model	M3030V	M3030A
Range(N2)	10 slpm~30 slpm	
Response Time	≤2 sec (option : ≤1 sec)	
Accuracy	±1% FS	
Repeatability	±0.25% FS	
In/out signal	0~5Vdc	0~5Vdc or 4~20mA
Supply Power	+15~+28Vdc, 350mA	
Max operating pressure	≤90 bar	
Max operating Temp.	0~50 °C	
Leak rate	1×10 ⁻⁹ atm · cc/sec	
Control Range	2~100% for max range	



Model M3030A
Mass Flow Controller

AT Crystals
20-100 °C

RC Crystals
20-300 °C

Inficon™ Type



—Aluminum—Gold—Silver
 Frequency: 5.975-5.993 MHz
 Resistance: <15 Ohms
 Finish: 7 microns RMS
 Diameter: 14mm
 Contour: Plano-Convex
 Cut: AT +/-2'

Aluminum and Gold
 Frequency: 5.975-5.993 MHz
 Resistance: <40 Ohms
 Finish: 7 microns RMS
 Diameter: 14mm
 Contour: Plano-Convex
 Cut: RC +/-1'

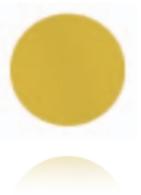
Balzers™



—Aluminum—Gold—Silver
 Frequency: 4.960-4.975 MHz
 Resistance: <15 Ohms
 Finish: 7 microns RMS
 Diameter: 14mm
 Contour: Plano-Convex
 Cut: AT +/-2'

Aluminum and Gold
 Frequency: 4.960-4.975 MHz
 Resistance: <40 Ohms
 Finish: 7 microns RMS
 Diameter: 14mm
 Contour: Plano-Convex
 Cut: RC +/-1'

Ulvac™ Type



—Aluminum—Gold—Silver
 Frequency: 4.990-5.900 MHz
 Resistance: <15 Ohms
 Finish: 7 microns RMS
 Diameter: 12.5mm
 Contour: Plano-Convex
 Cut: AT +/-2'

Aluminum and Gold
 Frequency: 4.990-5.900 MHz
 Resistance: <40 Ohms
 Finish: 7 microns RMS
 Diameter: 12.5mm
 Contour: Plano-Convex
 Cut: RC +/-1'

Gold is best suited for low stress coatings, metallization, and organic coatings
Silver is best suited for medium stress coatings and low stress optical films
Alloy is best suited for high stress coatings and dielectrics, refractory metals, CIGS and OLED
Nickel is best suited for high temperature applications of all films

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